NOTES:

1. SUBSTRATE:

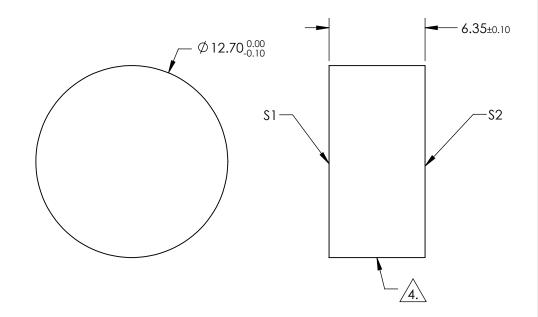
FUSED SILICA

- 2. SURFACE S2 TO BE PARALLEL TO SURFACE S1 TO WITHIN <3 ARCmin
- 3. COATING (APPLY ACROSS CLEAR APERTURE) S1: R(abs) S & P > 99.80% @ 800nm @ 45° AOI R(avg) > 99.5% @ 780 - 820nm @ 45° AOI

S2: NONE

4. FINE GRIND SURFACE

- 5. POWER, IRREGULARITY, AND SURFACE QUALITY SPECIFICATIONS APPLY ACROSS CLEAR APERTURE
- 6. CLEAR APERTURE AND COATING APERTURE ARE CENTERED ON SURFACES



FOR INFORMATION ONLY: DO NOT MANUFACTURE PARTS TO THIS DRAWING

SPECIFICATIONS SUBJECT TO CHANGE WITHOUT NOTICE DIMENSIONS ARE FOR REFERENCE ONLY

	\$1	\$2	
SHAPE	PLANO	PLANO	
SURFACE QUALITY	10 - 5	COMMERCIAL POLISH	
SURFACE FLATNESS	λ/10	N/A	
CLEAR APERTURE	Ø11.43	N/A	
COATING APERTURE	Ø11.43	N/A	
BEVEL	PROTECTED AS NEEDED	PROTECTED AS NEEDED	

GO ® Edmur			Edmund Optic	S®	
	THIRD ANGLE PROJECTION	12.7mm Dia., 6.35mm Thick, Fused Silica 800nm Ti:Sapphire Mirror, 45 Deg AOI			
	ALL DIMS IN	mm	DWG NO	28986	SHEET 45 OF 86